



JPW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q73370

Ryuji YAMAMOTO, et al.

Appln. No.: 10/727,044

Group Art Unit: 1755

Confirmation No.: 4853

Examiner: MARCHESCHI, Michael A.

Filed: December 04, 2003

For: COMPOSITE MATERIAL FOR POLISHING, GRINDING STONE, GRINDING MATERIAL, POLISHING MATERIAL AND PROCESSING METHOD FOR ELECTRONIC PARTS AND SILICON

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Restriction Requirement, October 19, 2005, Applicant elects Group II, claims 11-16 for examination. This election is made without traverse.

The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account.

Respectfully submitted,

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Date: November 21, 2005